INTERNATIONAL SEARCH REPORT

International Application No PCT/EP2004/052656

A. CLASSIFICATION OF SUBJECT MATTER IPC 7 G03F9/00 G03F G03F7/00 B29C59/02 According to International Patent Classification (IPC) or to both national classification and IPC Minimum documentation searched (classification system followed by classification symbols) IPC 7 G03F Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practical, search terms used) EPO-Internal, WPI Data, INSPEC C. DOCUMENTS CONSIDERED TO BE RELEVANT Relevant to claim No. Citation of document, with indication, where appropriate, of the relevant passages 24-27 US 2004/022888 A1 (SREENIVASAN SIDLGATA V P,X ET AL) 5 February 2004 (2004-02-05) paragraph '0215! - paragraph '0223! WO 99/15933 A (INTERNATIONAL BUSINESS 24-27 MACHINES CORPORATION: BIEBUYCK, HANS; MICHEL, B) 1 April 1999 (1999-04-01) column 4 - column 5; claim 19; figure 5 US 2003/128361 A1 (KURODA' RYO ET AL) Α 10 July 2003 (2003-07-10) cited in the application Patent family members are listed in annex. Further documents are listed in the continuation of box C. Special categories of cited documents: later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the *A* document defining the general state of the art which is not considered to be of particular relevance "E" earlier document but published on or after the international *X* document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to filing date *L* document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) involve an inventive step when the document is taken alone document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such docu-*O* document referring to an oral disclosure, use, exhibition or ments, such combination being obvious to a person skilled in the art. other means document published prior to the international filing date but later than the priority date claimed *&* document member of the same patent family Date of mailing of the international search report Date of the actual completion of the international search 10/10/2005 20 September 2005 Authorized officer Name and mailing address of the ISA European Patent Office, P.B. 5818 Patentiaan 2 NL – 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016 Haenisch, U

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